

In Re Application of:

Wang, Li-Shun and Chu, John

Serial No.: Not yet assigned

Filed: December 31, 1999

For: REMOVAL OF RESIDUE FROM A

SUBSTRATE

09/446033

0360

Atty. Docket No.: 042390.P7832

Ameld 5-250

Art Unit: Not yet assigned

Examiner: Not yet assigned

PRELIMINARY AMENDMENT

BOX NON-FEE AMENDMENTS Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

In connection with the above-referenced application filed on December 31, 1999, the Applicants respectfully request consideration of the following preliminary amendments and remarks.

IN THE SPECIFICATION

At page 1, line 5, after "metal", please delete the phrase "layer over".

At page 1, line 5, after "metal", please insert the following: --plug on--.

At page 1, line 20, after "tungsten", please replace "14" with --13--.

At page 1, line 20, after "layer", please replace "16" with --15--.

At page 1, line 21, after the first occurrence of "layer", please replace "16" with

At page 1, line 21, after "metal layer", please replace "14" with --13--.

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--15--.